

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of :  
Seung Wan CHAE : Confirmation No. -----  
U.S. Patent Application No. ----- : Group Art Unit: -----  
Filed: March 30, 2004 : Examiner: -----  
For: GALLIUM NITRIDE (GaN)-BASED SEMICONDUCTOR LIGHT EMITTING  
DIODE AND METHOD FOR MANUFACTURING THE SAME

**INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

Respectfully submitted,

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<b>INFORMATION DISCLOSURE CITATION IN AN APPLICATION</b>  <b>(PTO-1449)</b>				ATTY. DOCKET NO. <b>2336-255</b>		U.S. APPLICATION NO. -----	
				APPLICANT <b>Seung Wan CHAE</b>			
				FILING DATE <b>March 30, 2004</b>		GROUP -----	
<b>U.S. PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
	5563422	10/1996	Nakamura <i>et al.</i>				
<b>FOREIGN PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation Yes      No	
<b>OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)</b>							
EXAMINER				DATE CONSIDERED			

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.